

Thermal Fatigue Life in μ BGA and Flip Chip Solder Joints

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■ Education

1988 – 1992 : Faculty of Engineering, University of Osaka, Japan
Awarded the degree of PhD in Welding Engineering

■ Research and professional experience

1985 – 1987 : Researcher of Mechanical Technical Center,
Daewoo Heavy Industry Incheon, Korea.
1992 – 1994 : Principal Researcher of Packaging Team,
Semiconductor Technical Center,
Samsung Electronics Co., Ltd. Kihung, Korea.
1994 – 1997 : Assistant Professor of Department of Mechanical
Engineering Chung-Ang University, Seoul, Korea.
2001 - Present : Chair Professor of Department of Mechanical
Engineering Chung-Ang University, Seoul, Korea

Research Fields

1. Micro soldering processes – Wave Type

- Reflow Type (IR, Hot Air)
- Pulse Heat Tool Type
- Electric Resistance Type

2. Evaluation of Micro Joints

- Thermal Fatigue
- Life Prediction
- Aging Characteristic
- Migration
- Whiskers

3. Electronic packaging Processes

- Plating
- Wire Bonding
- TAB
- BGA

4. Development and design of new materials

- Lead Frame
- Solder Ball
- Under fill
- Lead Free Solder Paste

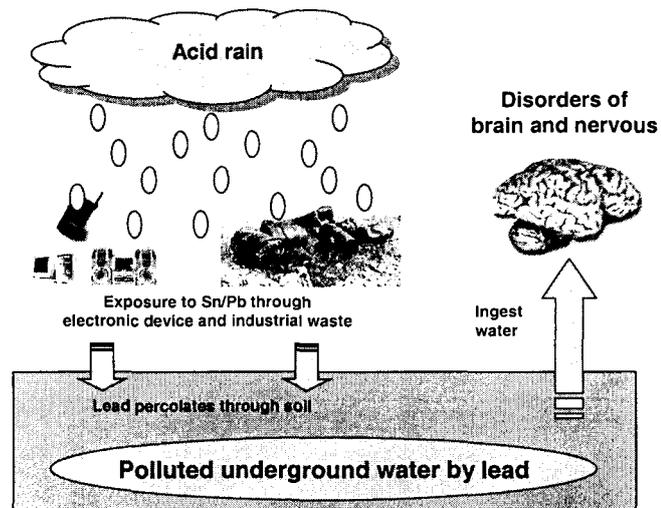
The Thermal Fatigue life of Lead-Free Solders in Micro BGA Solder Joints

Chung-Ang University

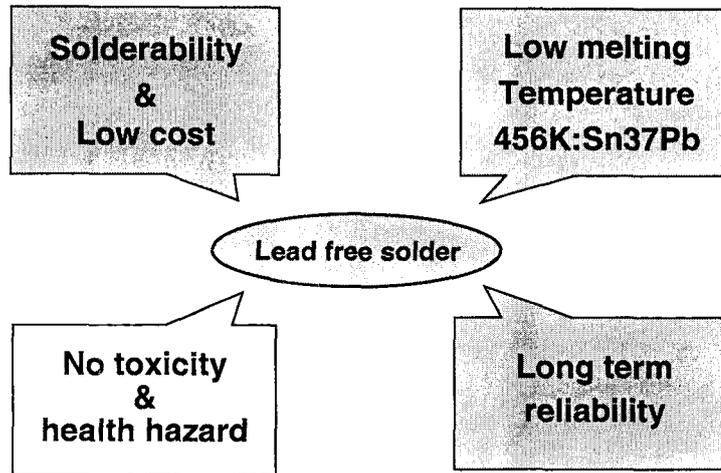
Young-Eui Shin

Introduction

Problems of Lead in the Environment

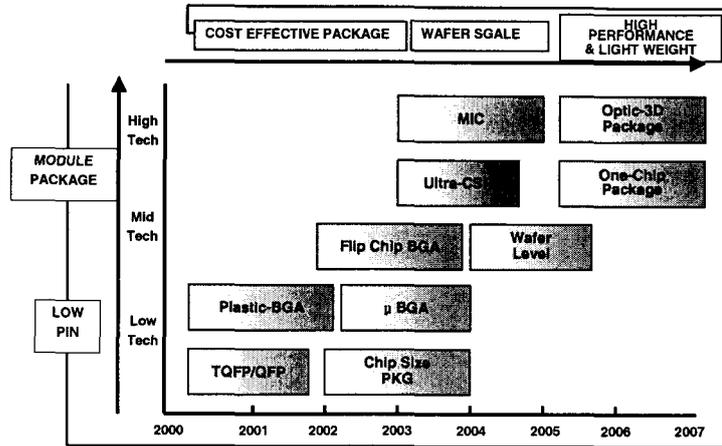


Requirements for Lead-free Solder

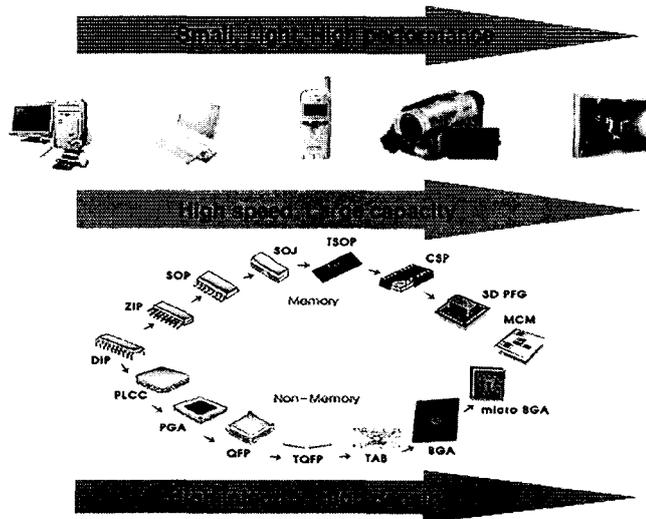
Compatible Lead-free Solder ($T_m > 479K$)

Alloy system	Company	Composition(mass%)
Sn-Ag	NEC (Japan)	Sn-3.5Ag-0.7Cu(Sn-3.5Ag(Mp:494K))
	Oki (Japan)	Sn-3.5Ag(-0.7Cu)
	Iowa State Univ. (USA)	Sn-4.7Ag-1.7Cu
	AIM Inc. (USA)	Sn-2.5Ag-0.8Cu-0.5Sb
Sn-Ag-Bi	Hitachi (Japan)	Sn-Ag-Bi(ex. Sn-2.5Ag-2.0Bi)
	Sony (Japan)	Sn-2Ag-4Bi-3.0In-0.1Ge
	Sandia National Lab. (USA)	Sn-3.4Ag-4.8Bi
Sn-Ag-Bi-In	Cookson Technol. C. (USA)	Sn-2Ag-7.5Bi-3.0In
	Matsushita (Japan)	Sn-Ag-Bi-In (Sn-2.5Ag-2Bi-3In)
	Toyota (Japan)	Sn-2.5Ag-3Bi-1In-0.2Cu
Sn-Ag-Bi-In	Mitsui (Japan)	Sn-2.5Ag-2.5Bi-2.5In
	Toshiba (Japan)	Sn-8.8Zn(T_m :472K)
Sn-Cu	IEC electronics corp. (USA)	Sn-0.7Cu (T_m :493K)
	Matsushita (Japan)	Sn-0.7Cu-X
Sn-Bi	Fujitsu (Japan)	Sn-58Bi (T_m :412K)

Package Technology



Package Trends

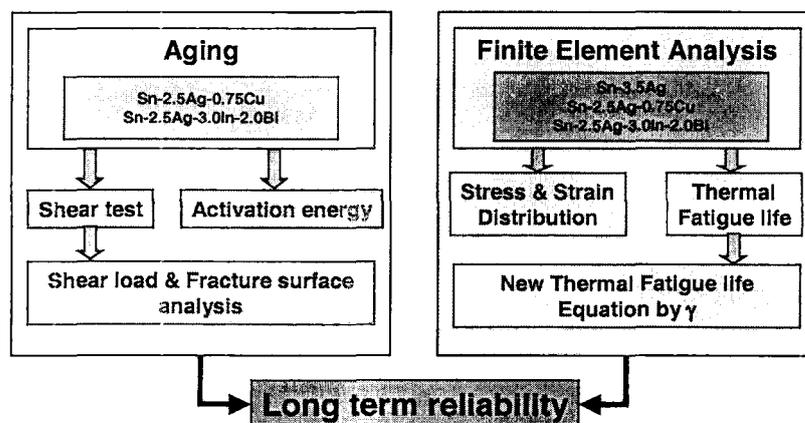


Content 1

Solder joint Fatigue Models & FE Analysis Procedure

Content 1

Approach method of Aging & Thermal Fatigue Life

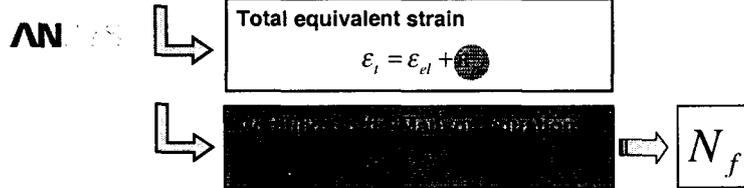


Thermal Fatigue Life Evaluation

Von-mises yield condition equation

$$\sigma_{vm} = \frac{1}{\sqrt{2}} \left[(\sigma_1 - \sigma_2)^2 + (\sigma_2 - \sigma_3)^2 + (\sigma_3 - \sigma_1)^2 \right]^{1/2}$$

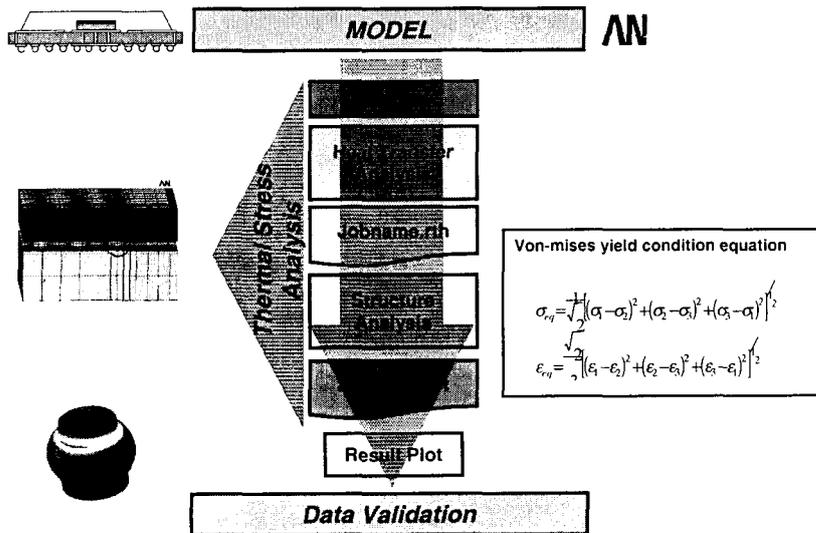
$$\epsilon_{vm} = \frac{\sqrt{2}}{3} \left[(\epsilon_1 - \epsilon_2)^2 + (\epsilon_2 - \epsilon_3)^2 + (\epsilon_3 - \epsilon_1)^2 \right]^{1/2}$$



Fatigue constant(C) and Fatigue exponent(α) of four different solder alloy

	Sn-37Pb	Sn-3.5Ag	Sn-2.5Ag-0.7Cu	Sn-2.5Ag-3.0In-2.0Bi
C	0.24	0.90	0.56	0.45
α	0.49	0.6	0.53	0.51

Finite Element Analysis Procedure



Von-mises yield condition equation

$$\sigma_{vm} = \frac{1}{\sqrt{2}} \left[(\sigma_1 - \sigma_2)^2 + (\sigma_2 - \sigma_3)^2 + (\sigma_3 - \sigma_1)^2 \right]^{1/2}$$

$$\epsilon_{vm} = \frac{\sqrt{2}}{3} \left[(\epsilon_1 - \epsilon_2)^2 + (\epsilon_2 - \epsilon_3)^2 + (\epsilon_3 - \epsilon_1)^2 \right]^{1/2}$$

Solder Joint Fatigue Models

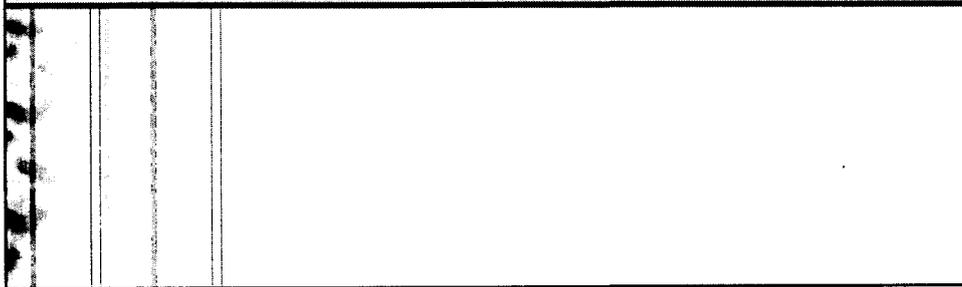
Fatigue Models	Model Class	Required Parameters	Coverage
Coffin-Manson	Plastic strain fatigue model	Plastic strain	Low cycle fatigue
Coffin-Manson-Basquin	Plastic strain fatigue model	Plastic strain + Elastic strain	High and low cycle fatigue
Solomon	Plastic strain fatigue model	Plastic shear strain	Low cycle fatigue
Engelmaier	Plastic strain fatigue model	Total shear strain	Low cycle fatigue
Shin	Plastic strain fatigue model	Plastic strain	Low cycle fatigue
Knecht and Fox	Creep strain fatigue model	Matrix creep shear strain	Matrix creep only
Darveaux	Energy based model	Damage + energy	Hysteresis curve

Characteristics of Each Fatigue Model

Plastic strain based fatigue model	Creep strain based fatigue model	
<p>Coffin-Manson</p> <ul style="list-style-type: none"> • Best known & Most widely used approach • Only considers plastic deformations 	<p>Knecht & Fox</p> <ul style="list-style-type: none"> • Simple matrix creep fatigue model (Only considers dislocation movement of solder) • Doesn't account for grain boundary creep 	
<p>Coffin-Manson-Basquin</p> <ul style="list-style-type: none"> • Total strain which also covers elastic deformation 		
<p>Solomon</p> <ul style="list-style-type: none"> • Plastic shear strain range unlike Coffin-Manson equation (Plastic strain amplitude) • Doesn't account for creep behavior → limitation in its practical use for solder joints 		
<p>Engelmaier</p> <ul style="list-style-type: none"> • Total shear strain with cyclic frequency and temperature • Based on isothermal experimental fatigue data → limited in application to new model 		
<p>Shin</p> <ul style="list-style-type: none"> • Plastic strain amplitude with temperature dependent factor γ • Doesn't account for creep behavior 		
	<th>Energy based fatigue model</th>	Energy based fatigue model
	<p>Dasgupta</p> <ul style="list-style-type: none"> • Total strain energy → Good indicator of solder joint damage 	
	<p>Darveaux</p> <ul style="list-style-type: none"> • Incorporates crack propagation (overcomes limitation of previous energy-based model) • Include energy density term from stress-strain hysteresis curve 	

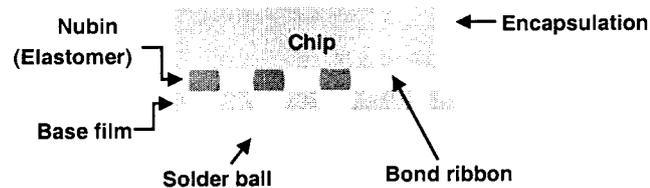
Content 2

Experimental & Theoretical Thermal Fatigue Life Evaluation of μ BGA



Content 2

48 μ BGA Package



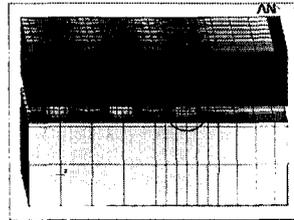
Package profile

- Ball count : 48 (6×8)
- Body size : 6.3×6.2mm
- Ball size & pitch : 0.35mm, 0.75mm
- Base film thickness : 50 μ m
- Chip thickness : 0.43mm
- Cu(Au) thickness : 18(1.0 \pm 0.3) μ m

Application

- Memory card & devices
- SRAM, DRAM, FLASH
- Laptop PCs, Hard Drives
- Camcorders, Cellular Phones

Finite Element Modeling of 48 μ BGA



(a) Full shape after modeling

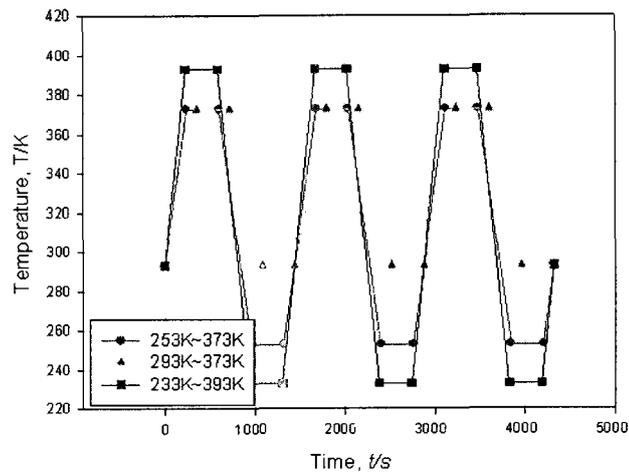


(b) Solder joints



(c) Solder ball shapes

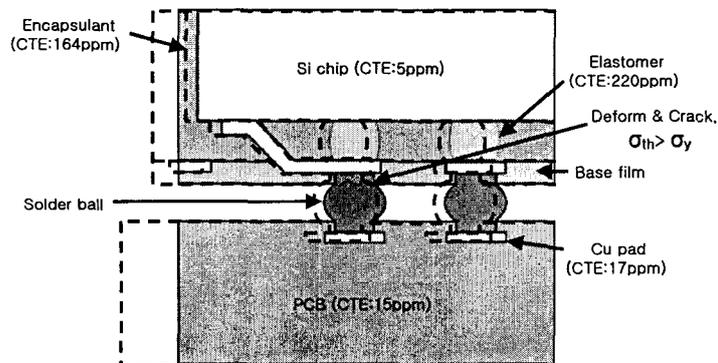
Temperature Profile for TC Test



Mechanical Properties of Components

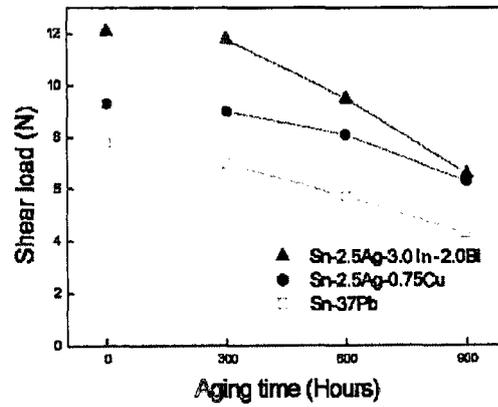
	Density (ρ :kg/mm ³)	Elastic Modulus (E:Gpa)	Coefficient Thermal Expansion (CTE :ppm)	Poisson's Ratio (ν)	
Si chip	2.33E-6	188	23	0.25	
Encapsulant	1.77 E-6	2.54	164	0.4	
Elastomer	1.03 E-6	0.25	220	0.45	
Cu pad	8.92 E-6	119	17	0.343	
Base film	1.6 E-6	4	17	0.35	
S o l d e r	Sn-Pb	8.42 E-6	25.8	21.4	0.4
	Sn-Ag	7.36 E-6	43.2	30	0.3
	Sn-Ag-Cu	7.4 E-6	45.1	23	0.3
	Sn-Ag-In-Bi	7.3 E-6	42.0	25	0.3
PCB	1.03	0.25	220	0.45	

Thermal Fatigue Failure at Solder Joints



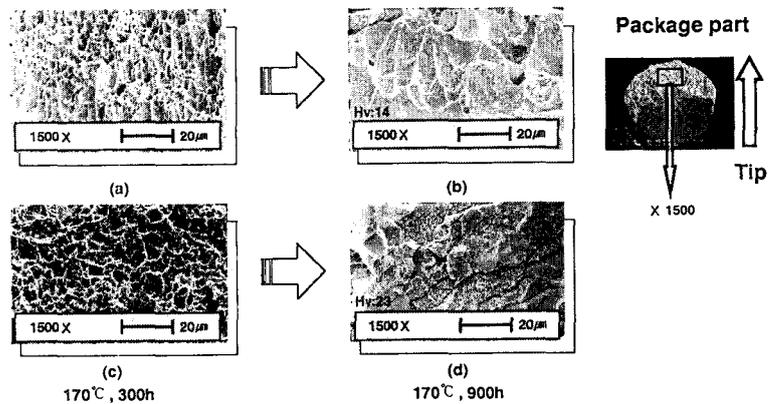
Thermal stress concentration mechanism

Shear Load



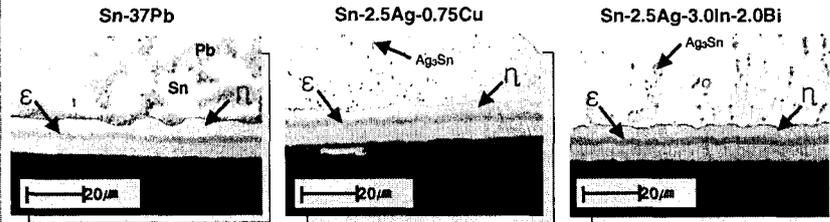
Relation between aging time and shear load with solder alloys at aging temperature 170°C

Fracture Surface after Shear Test



Fracture surface of Sn-Ag-Cu(a,b) and Sn-Ag-In-Bi(c,d)

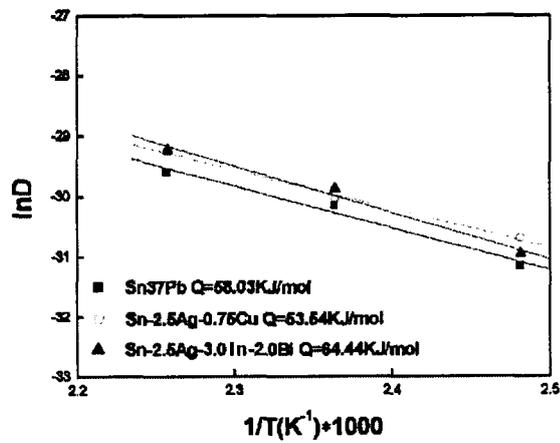
Intermetallic Compound Layers



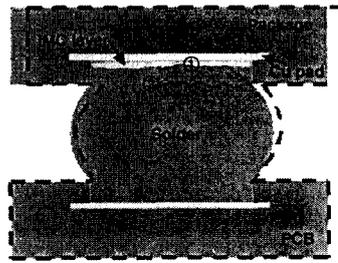
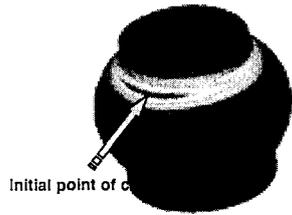
ϵ : Cu_3Sn η : Cu_6Sn_5

Phases of the intermetallic compound layer by aging(170 °C, 900h)

Activation Energy of Sn-Pb and Lead-free Solders



Stress Concentration Area and Crack Growth Mode

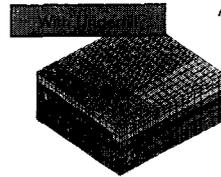
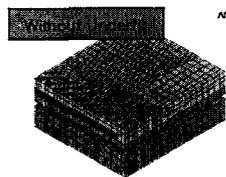


Mode 1 : Interface fracture of solder and IMC layer
 Mode 2 : Solder inside fracture

(a) FEA results for effective to the thermal cycling

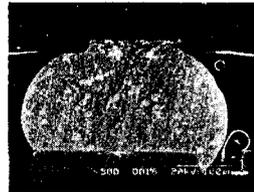
(b) Growth mode of the crack

Stress Distribution & Theoretical Results by Engelmaier's Fatigue Model

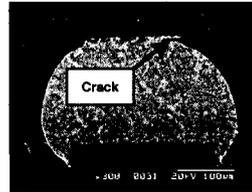


	Without underfill	With underfill
σ_{max} (MPa)	1.5212	0.5353
σ_{min} (MPa)	1.5664	0.5796
$\Delta\sigma$ (MPa)	2.7131	1.0038
N_f	1405	16873

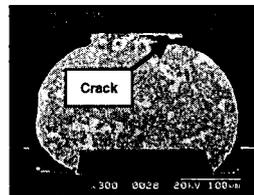
Cross Sectional View of Solder Joint without Underfill ($\Delta K: 160K$)



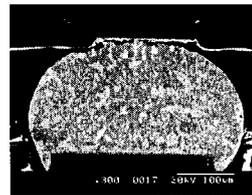
(a) After 500 cycles



(b) After 600 cycles

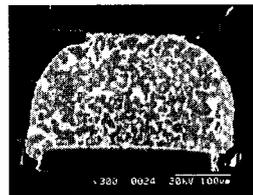


(c) After 700 cycles

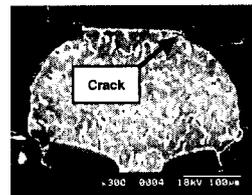


(d) After 800 cycles

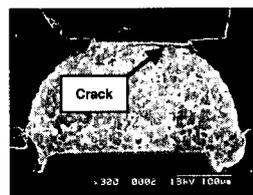
Cross Sectional View of Solder Joint with Underfill ($\Delta K: 160K$)



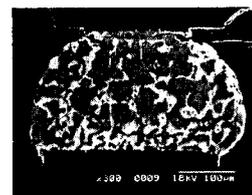
(a) After 4500 cycles



(b) After 5000 cycles



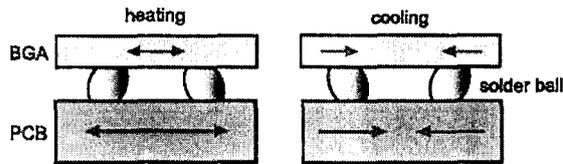
(c) After 5500 cycles



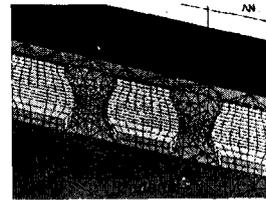
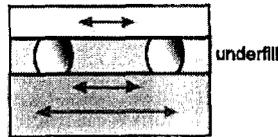
(d) After 6000 cycles

Failure Mechanism of Solder Ball with Underfill

Thermomechanical deformation without underfill



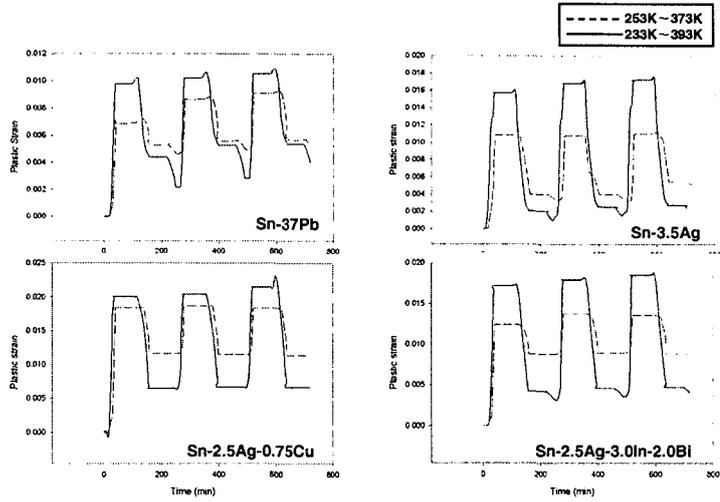
Thermomechanical deformation with underfill



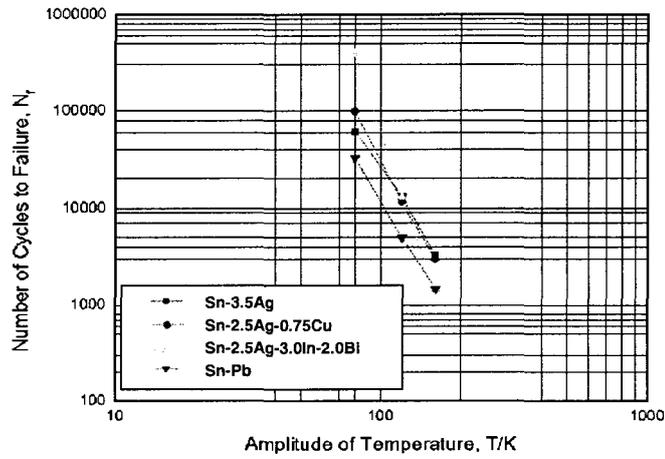
Mean Elastic-Plastic Strain Amplitude under Various Conditions

		$T_{cycle}(K)$	Sn-37Pb	Sn-3.5Ag	Sn-2.5Ag-0.75Cu	Sn-2.5Ag-3.0In-2.0Bi	
ΔE_{pl}	253 ~ 373	293 ~ 373	0.000592	0.000267	0.000347	0.000303	
		30 °	0.000799	0.000248	0.000427	0.000317	
			50 °	0.000599	0.000209	0.000321	0.000257
			70 °	0.000718	0.000332	0.000372	0.000383
	233 ~ 393	0.000915	0.000381	0.000489	0.000483		
ΔE_{pl}	253 ~ 373	293 ~ 373	0.004766	0.003626	0.003713	0.000848	
		30 °	0.012684	0.004778	0.008242	0.007859	
			50 °	0.009675	0.002363	0.004996	0.004945
			70 °	0.014836	0.005347	0.008377	0.008768
	233 ~ 393	0.015847	0.014668	0.014786	0.015806		

Strain Hysteresis Curves by Solder Alloy



Correlation of log ΔT vs log N_f



Temperature Dependent Dimensionless Factor γ

$$\gamma = \frac{\Delta T \cdot T_{mean}}{\frac{1}{2} T_M \cdot T_0}$$

ΔT : difference of temperature
 $T_{mean}(K)$: mean temperature of thermal cycle
 $T_M(K)$: melting point
 $T_0(K)$: Reference temperature of thermal expansion

$$N_f = 10^{\log A + \beta \log \gamma}$$

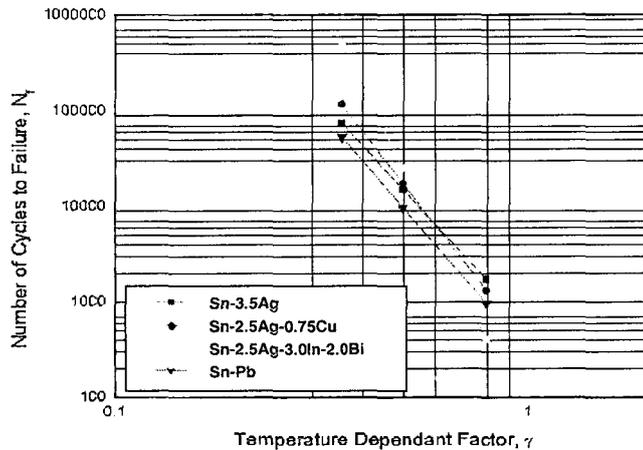
$$N_f = A(\gamma)^\beta$$

A : Fatigue material constant
 β : Fatigue material exponent

Calculated fatigue constant of various solder with γ

	Sn-37Pb	Sn-3.5Ag	Sn-2.5Ag-0.75Cu	Sn-2.5Ag-3.0In-2.0Bi
logA	2.492	2.774	2.565	1.716
β	- 4.967	- 4.660	- 5.561	- 8.887

Log-log Graph of γ vs N_f



Conclusion. 1

1) Sn-Ag base solder alloys could be expected that the initial crack formation is more difficult because of a little change of the structure by aging and TC test compared to that of Sn-Pb solders.

2) The thermal fatigue life equation is derived using the dimensionless variable γ obtained from ΔT , T_m , T_{mean} for life evaluation of μ BGA. In addition, the results with γ show a better linearity than using only ΔT .

3) At low temperature range from 293K to 373K, Sn-2.5Ag- 3.0In-2.0Bi shows the longest fatigue life. Moreover, at the temperature range from 233K to 393K, Sn-3.5Ag shows the longest fatigue life.

Conclusion. 2

Future Trends of Micro Joining

The Joining Reaction Layer Control Technology

The Joining Interface Analysis Technology

Low Temperature Joining Technology

New Materials Development

The Establishment of Evaluation Technology